

## Correction to A Noninvasive Method for Nanoscale Electrostatic Gating of Pristine Materials

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### Supporting Information

In the original paper, Figure S3b of the Supporting Information erroneously showed the trace of the left QPC and not of the right QPC; therefore Figure S3b is identical to Figure 2d of the main text. The correct trace, for the right QPC, is shown in the corrected file.

### ASSOCIATED CONTENT

#### Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: [10.1021/acs.nanolett.6b01040](https://doi.org/10.1021/acs.nanolett.6b01040).

Methods, analysis, and extra figures ([PDF](#))

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